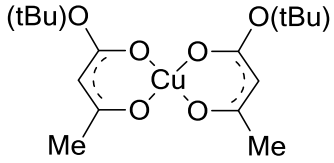
Catalog # B282541 Bis(t-butylacetoacetato)copper(II), 99%



Technical Notes:

1. A new, non-fluorinated, copper CVD precursor exhibiting a higher sublimation rate and lower decomposition rate than $Cu(dpm)_2$
2. Copper CVD precursor used in the deposition of copper films with low carbon content [2]

References:

1. *J. Mater. Res.*, **1998**, *13*, 687.
2. *Surface and Coating Technology*, **2002**, *150*, 205.